

IN THE CLAIMS

Please amend the claims in accordance with the following rewritten claims in clean form. Applicant includes herewith an Attachment for Claim Amendments showing a marked up version of each amended claim.

Sub
E1
D1

8. (Thrice Amended) A liquid-crystal display device comprising:
a first substrate having an inner surface;
a second substrate having an inner surface;
a liquid-crystal layer disposed between said first and second substrates;
a wiring layer formed on at least one of said inner surfaces of said first and second substrates, said wiring layer including a connection portion;
a pixel electrode connected to the connection portion of said wiring layer; and
an insulating film overlapping at least a portion of the wiring layer, the insulating film not overlapping the connection portion and another area of the pixel electrode, said another area extending from the connection portion.

Sub
E2
D2

16. (Thrice Amended) A method of forming a liquid-crystal display device comprising:
providing a first substrate having an inner surface;
providing a second substrate having an inner surface;
forming a wiring layer on at least one of said inner surfaces of said first and second substrates, said wiring layer including a connection portion;
forming an insulating film on at least a portion of the wiring layer; and

D2 E2
forming a pixel electrode that is connected to the connection portion of the wiring layer, the insulating film not overlapping the connection portion and another area of the pixel electrode, said another area extending from the connection portion.

Sub E3
D3
29. (Amended) A substrate with an active element, comprising:
a base member;
a wiring layer including a connection portion; and
a pixel electrode electrically connected to the connection portion of said wiring layer such that the active element is formed; and
an insulating film overlapping at least a portion of the wiring layer, the insulating film not overlapping the connection portion and another area of the pixel electrode, said another area extending from the connection portion.

Sub E4
D4
39. (Amended) A substrate with an active element, comprising:
a base member;
a wiring layer including a connection portion; and
a pixel electrode electrically connected to the connection portion of said wiring layer such that the active element is formed; and
an insulating film overlapping at least one of the wiring layer and a peripheral portion of the pixel electrode, such that said pixel electrode has a first and a second region, the pixel electrode and the insulating film overlapping each other in the first region and the insulating film not overlapping the connection portion and the second region of the pixel electrode, the second region extending from the connection portion.

40. (Amended) A substrate with an active element, comprising:

a base member;

a wiring layer including a connection portion; and

a pixel electrode electrically connected to the connection portion of said wiring layer such that the active element is formed; and

an insulating film overlapping at least a portion of said wiring layer, such that said pixel electrode has a first and a second region, the pixel electrode and the insulating film overlapping each other in the first region and the insulating film not overlapping the connection portion and the second region of the pixel electrode, the second region extending from the connection portion.

41. (Amended) A substrate with an active element, comprising:

a base member;

a wiring layer including a connection portion; and

a pixel electrode electrically connected to the connection portion of said wiring layer such that the active element is formed; and

an insulating film overlapping at least a peripheral portion of the pixel electrode, such that said pixel electrode has a first and a second region, the pixel electrode and the insulating film overlapping each other in the first region and the insulating film not overlapping the connection portion and the second region of the pixel electrode, the second region extending from the connection portion.

42. (Amended) A substrate with an active element, comprising:
a base member;
a wiring layer including a connection portion; and
a pixel electrode electrically connected to the connection portion of said wiring layer such that the active element is formed; and
an insulating film being arranged so that at least one of said connection portion and said wiring layer overlaps the insulating film, said pixel electrode having a first and a second region, the pixel electrode and the insulating film overlapping each other in the first region and the insulating film not overlapping the connection portion and the second region of the pixel electrode, the second region extending from the connection portion.

43. (Amended) A method of forming a substrate with an active element, comprising the steps of :
providing a base member;
forming a wiring layer including a connection portion;
forming a pixel electrode that electrically connects to the connection portion of said wiring layer such that the active element is formed; and
forming an insulating film so that at least one of said wiring layer and a peripheral portion of said pixel electrode overlaps the insulating film, wherein the insulating film does not overlap the connection portion and another area of the pixel electrode, the area extending from the connection portion.